

**A SYSTEM AND METHODOLOGY FOR CALCULATING
THE COST OF FUTURE SEMICONDUCTOR PRODUCTS
USING REGRESSION ANALYSIS OF HISTORICAL COST DATA**

ABSTRACT

5 A method and structure for predicting semiconductor product costs at a
fabricator entailing a storage medium which includes a database of historical
critical dimensions and historical critical groundrules correlated to cost functions
at the fabricator. The user interface has user inputs for new design parameters and
new critical groundrules associated with a new device to be produced at the
10 fabricator and a computer adapted to receive the user inputs, extract data from the
storage medium, and compute semiconductor costs for the new device. The
historical critical dimensions and the new critical dimensions are gate dimensions
and the new critical dimensions are smaller than the historical critical dimensions.
This device includes a future technology generation. Fabrication hardware and
15 fabrication methods for producing the future technology generation are unknown
and the relationships comprise base models and models that include options. The
relationship comprise models that illustrate that costs increase exponentially as the
historical critical dimensions and the historical critical groundrules are reduced.